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Magnetic noise from ultra-thin abrasively deposited materials on diamond

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Sensing techniques based on the negatively charged nitrogen-vacancy (NV) centre in diamond have emerged as promising candidates to characterise ultra-thin and 2D materials. An outstanding challenge to this goal is isolating the contribution of 2D materials from undesired contributions arising from surface contamination, and changes to the diamond surface induced by the sample or transfer process. Here we report on such a scenario, in which the abrasive deposition of trace amounts of materials onto a diamond gives rise to a previously unreported source of magnetic noise. By deliberately scratching the diamond surface with macroscopic blocks of various metals (Fe, Cu, Cr, Au), we are able to form ultra-thin structures (i.e. with thicknesses down to < 1 nm), and find that these structures give rise to a broadband source of noise. Explanation for these effects are discussed, including spin and charge noise native to the sample and/or induced by sample-surface interactions, and indirect effects, where the deposited material affects the charge stability and magnetic environment of the sensing layer. This work illustrates the high sensitivity of NV noise spectroscopy to ultra-thin materials down to sub-nm regimes – a key step towards the study of 2D electronic systems – and highlights the need to passivate the diamond surface for future sensing applications in ultra-thin and 2D materials.

In recent years, quantum sensing techniques utilising negatively charged nitrogen-vacancy (NV) centres in diamond have been turned to interrogate condensed matter systems external to the diamond host. Among these, ultra-thin and 2D materials are of keen interest, given the unique consequences of low-dimensionality for electronic, magnetic, and transport properties, and one that NV sensing is particularly applicable to, given its high-sensitivity at nm length scales. Experiments using single NV centres have demonstrated nuclear magnetic resonance measurements of atomically thin materials, while dense NV ensemble measurements have magnetically imaged charge transport in mono-layer graphene. Additionally, the ability to discriminate between different transport regimes and identify impurities within 2D materials based on their magnetic noise profiles has been outlined theoretically, and should be similarly applicable to 1D systems.

Quantum imaging of 2D materials with NV-diamond substrates presents a set of challenges, primarily regarding sample-induced changes to the diamond surface and sensing layer, that may obscure direct contributions from the sample, which itself may be altered during fabrication or transfer processes, or by sample-surface interactions. Furthermore, there exists a range of possible contaminants present in the standard preparation techniques used for NV quantum sensing, the effects of which have not been well described, particularly in the context of 2D materials. In this work, we utilise a soft abrasion technique to deliberately deposit trace amounts of material onto diamond substrates, and characterise the resulting magnetic noise via quantum measurements of the near-surface ensemble of NV spins. Initially, results are presented for the abrasive deposition of stainless steel, which is shown to leave ferromagnetic nano-particles on the diamond down to 20 nm in size, the magnetic fields of which are imaged by optically detected magnetic resonance (ODMR). Additionally, the deposited material, including a thin coverage down to < 1 nm in thickness seen in the scratch region, is found to be the source of broadband magnetic noise that quenches the NV-layer spin-lattice relaxation time, $T_1$. Similar results are found from the deposition of other metallic materials, namely copper, chromium, and gold, whereas insulating materials, such as silicon, produce no such effect.

The negatively charged nitrogen-vacancy (NV) centre in diamond is an atom-sized defect comprised of a substitutional nitrogen and adjacent vacancy, that is capable of measuring static-to-GHz frequency magnetic fields. The spin-state dependent photoluminescence (PL) of this spin-1 system allows all-optical readout of the NV spin-state, and hence dense NV ensembles can be used for wide-field magnetic imaging of samples at the diamond surface. In these experiments, we use a (100) oriented single crystal diamond, with surfaces as-grown by chemical vapour deposition, implanted with nitrogen ions at 4 and 6 keV, giving NV centres at mean depths of about 10 nm and 15 nm respectively (see Appendix A for details). All NV measurements were performed in ambient conditions using a purpose-built wide-field microscope similar to that described in Ref, which has a spatial resolution of ≈ 400 nm, close to the diffraction limit. In this configuration, the NV-layer is sensitive to magnetic noise.
arising from 2D and ultra-thin materials at the surface, either in the form of spin-noise or charge-noise (i.e. magnetic noise associated with the movement of charge carriers), and also noise arising from defect states within the diamond, the population and dynamics of which may be altered by the presence of the sample. These scenarios are illustrated in Fig. 1.

The abrasive deposition of materials onto diamond was achieved by manually dragging the tip of a macroscopic block of a given material across the fixed diamond surface [Fig. 2a], in a region previously characterised by NV measurement (appendix B). First, we explore the consequences of depositing stainless steel by this technique, a particularly relevant study given its ubiquity in laboratory environments in many forms, such as tweezers, which were used for the deposition in this instance. Figure 2b is an image of the deposition region, taken by collecting the NV-layer PL after excitation with a 532 nm laser. The image shows quenching of the NV PL by up to 20% in streaked patterns, 10’s of µm in length. The observed quenching is possibly due to light scattering by the deposited material, near-field coupling, or discharging of the NV centres (becoming charge neutral, NV°) induced by the sample. An optical micrograph of this region shows micron-scale particulate features within the regions of greater PL quenching (becoming charge neutral, NV°) induced by the sample. These regions are illustrated in Fig. 2c, d, e, and f are identical. 

FIG. 1. a Schematic of the quantum imaging of 2D and nanoscale materials. Samples are transferred onto a single crystal diamond (blue) which contains a dense layer of near-surface NV centres (unit cell). Optical readout is achieved by wide-field illumination with a 532 nm laser, and the photoluminescence (PL) is collected on a sCMOS camera for imaging. b Ground state structure of the spin-1 NV centre, where the Zeeman splitting of the dark ±1 states, relative to the bright 0 state, allows static magnetic fields to be imaged. The transition frequencies ω± determine the region of spectral sensitivity of the NV spin-state to magnetic noise, and hence their relaxation rates. c Illustration of potential magnetic noise sources (purple) in 2D magnetic imaging with near-surface NV centres (red). Spin- and charge-noise may arise from the 2D material of interest (bonded structure), or from atomic and particulate inclusions, which may also exude static magnetic fields (orange). Magnetic noise may also arise from defects within the diamond, such as substitutional nitrogen (blue), or vacancies (white), the population and dynamics of which may be affected by the sample at the surface. 

FIG. 2. a Schematic showing abrasive deposition of materials on diamond. The material (grey) is dragged across the diamond surface (blue), leaving material residues down to sub-nm thicknesses. b PL image acquired from the NV-layer, showing streaked PL quenching due to the deposited stainless steel. c Magnetic field image (Bz component) as reconstructed from an ODMR measurement of the NV layer. The z-scale is capped at ±20 µT to highlight lesser field strengths. The largest fields measured are approximately 100 µT in magnitude. d ODMR contrast map for a single NV family spin transition (see appendix B, Fig. 7). e and f show a zoom-in of the static field image and an AFM topography map respectively, of the same region, showing the correlation of static magnetic fields with the location of particles of size > 20 nm in height. In f, the z-scale is capped at 30 nm to emphasise smaller features. Central particles are > 500 nm in height. The regions presented in b, c, and d are identical.
ODMR measurement was performed, with an external magnetic field applied across the NV-layer, such that the two electron-spin transition frequencies of each of the four NV orientation families are resolved\cite{21}. The spin-state dependent PL of the NV centre allows these transition frequencies to be measured optically, and acquisition of the PL with a camera allows pixel-by-pixel ODMR spectra to be constructed. Fitting the spectra in accordance with the NV spin-Hamiltonian, static magnetic fields can be mapped across the field of view and calibrated to the NV orientation families resolved\cite{7,21}. Two electron-spin transition frequencies of each of the four NV orientation families are resolved\cite{7,21}.

The magnetic dipole signatures are correlated with particles present at the diamond surface, with heights ranging from 20 nm to 500 nm. Energy-dispersive X-ray spectroscopy (EDXS) of larger particles from a similarly prepared sample confirm the presence of iron and oxygen, suggesting that the particles are iron oxide, Fe$_3$O$_4$ (appendix \[D\]).

In addition to reconstructing magnetic field strengths from the NV spin-transition frequencies, the optical contrast of these transitions can be mapped across the same region. Figure 2 maps the magnetic field strength oriented along the $y$-direction, $B_y$, which is representative of the in-plane magnetic field \((B_x \text{ and } B_z \text{ components are shown in appendix} \[C\])\). The regions identified previously by their strong PL quenching contain ferromagnetic moments, with field strengths measured up to $\sim 100 \mu$T. Comparing a zoomed-in magnetic field image [Fig. 2] with an atomic force microscopy (AFM) image of the same region [Fig. 3], it is clear that the magnetic dipole signatures are correlated with particles present at the diamond surface, with heights ranging from 20 nm to 500 nm. Energy-dispersive X-ray spectroscopy (EDXS) of larger particles from a similarly prepared sample confirm the presence of iron and oxygen, suggesting that the particles are iron oxide, Fe$_3$O$_4$ (Fe$_3$O$_4$) (appendix \[D\]).

In addition to reconstructing magnetic field strengths from the NV spin-transition frequencies, the optical contrast of these transitions can be mapped across the same region. Figure 2 shows a map of the ODMR contrast for the lowest frequency transition, where the contrast is significantly reduced at sites of ferromagnetism, due to broadening from the static field gradient\cite{21}. However, the contrast map shows additional reductions in contrast beyond the regions of large magnetic field strengths and PL quenching, suggesting an additional effect of the deposited material on the NV-layer. The AFM data shows that one such region is bounded by $< 10 \text{ nm}$ tall ridges oriented along the direction of the abrasions, which do not show in the optical, PL, or magnetic micrographs. Given the transition of iron oxide from ferromagnetism to super-paramagnetism at sizes $< 10 \text{ nm}$\cite{22}, imaging fluctuating magnetic fields is necessary to further characterise the system.

$T_1$-relaxometry\cite{23} is an established technique in NV-sensing which allows the detection of magnetic noise at the electron spin sub-level transition frequency\cite{23,25}. In this measurement, the NV is initialised in the bright state, $|0\rangle$, by a polarising laser pulse, and left to evolve towards a thermal mixture with the dark states, $|\pm_1\rangle$, before being optically read out by a second laser pulse. The observed decay in readout PL for this measurement is normalised by that from an intercalated sequence, which includes a microwave $\pi$-pulse, resonant with $\omega_\perp$, before the readout laser pulse, such that common mode variations are removed from the measurement. Here, all $T_1$-relaxometry imaging were performed at zero-field, i.e. with the NV spin-transition frequencies at $\omega_\perp = 2.87 \text{ GHz}$, optimising acquisition time and optical contrast, unless otherwise stated.

Figure 3 shows a $T_1$-relaxometry image of the previously analysed region of abrasively deposited stainless steel. Here, we see up to an order of magnitude reduction in the $T_1$-relaxation time of the NV-layer under the abraded region, which covers a far greater area than suggested by the PL and static magnetic field images. Comparing this data to a scanning electron microscope (SEM) image of the same region, we see the same pattern in the secondary electron emission contrast [Fig. 3a]. Individual relaxation curves used to compose the $T_1$ map are shown in Fig. 3, for neighboring areas beside and under the abrasion, with $T_1$-relaxation times of 1.79 ms and 0.57 ms respectively. This corresponds to an increase in relaxation rate $\Delta T_1 = (1/T_1)_{\text{abraded}} - (1/T_1)_{\text{bare}} \approx 1.8 \text{ kHz}$. Additionally, the noise spectra of a bare and more heavily abraded diamond regions is shown in figure 3, measured by aligning the external magnetic field with a single NV orientation and varying the field strength, using the NV $|0\rangle \leftrightarrow |\text{b}1\rangle$ transition as a spectral filter\cite{22,23}. Over a range of 800 G, there is an approximately constant offset of 4.5 kHz between the spectra of the bare diamond and the abraded region, suggesting that the abrasive deposition adds a broadband source of magnetic noise to the sample. The enhanced relaxation rate around 512 G in both spectra is due to a cross-relaxation resonance with unpaired electron spins intrinsic to the diamond\cite{10,29}.

One striking difference between the SEM and $T_1$ images presented is the clear texturing of the abraded region seen in SEM, as compared to the more uniform $T_1$ maps. This difference is emphasised by comparing higher-resolution SEM images with a zoom-in of the $T_1$ map [Fig. 3 and f respectively]. The optical resolution limited $T_1$ map shows relatively flat quenching under the abraded regions, where the SEM image shows large variations in contrast, and clear streaking along the direction of the abrasion. The topography of this region, as mapped by AFM, shows some of the same structures [Fig. 3g]. The dark streak running along the edge of the abraded region is a collection of nano-particles, 5-10 nm in height. An approximately 1.0 nm step height is seen across the upper branch of deposited material, that matches spatially with the observed $T_1$ quenching within the resolution of our imaging [Fig. 3h]. The definition of the lower branch in AFM and $T_1$ is less well correlated across its full width, suggesting a sparse deposition below the noise floor of the AFM is responsible for the quenching here.

To gain further insight into the origin of this magnetic noise, we repeated the previous experiments of soft abrasion deposition, replacing the stainless steel (from tweezers) with a piece of silicon (from a wafer), and blocks of pure copper and chromium (see Appendix \[A\]). Additionally, in a control experiment, a diamond scribe was used instead to study the possibility of structural changes due to the abrasion process. Figure 4 presents PL, $T_1$-relaxometry, and AFM images of the four additional ma-
The abrasion of NV-diamond substrate with a diamond scribe results in a dramatic quenching of NV PL under the abraded regions [Fig. 4i], however, the $T_1$-relaxometry map of the same region shows no significant changes [Fig. 4j]. The data so far has demonstrated that the abrasive deposition of copper and chromium [Figs. 4i - l and m - p respectively], however, bare resemblance to those for stainless steel. The abrasive deposition of copper, despite not resulting in a PL quenching [Fig. 4i], does quench $T_1$-relaxation [Fig. 4i]. Imaging the same region with AFM [Fig. 4k and l], a 1 nm step height from the bare diamond to the abrasively deposited copper is associated with a $T_1$ quenching from 0.4 ms to 0.3 ms, i.e. an increase to the NV relaxation rate of $\Delta \Gamma \approx 3\text{kHz}$. Chromium, on the other hand, shows some streaks of quenched PL [Fig. 4m], that run parallel to a large $T_1$ quenched feature [Fig. 4m]. AFM imaging of the same region shows that the PL quenched features are due to some apparently metallic deposition, 10-20 nm in height [Fig. 4n], however, there is no clear step height correlated with the $T_1$ quenched regions, despite a 0.5 kHz increase to the relaxation rate in the abraded region. Again, this suggests a sparse coverage of material, close to the noise floor of the AFM ($\sim 0.5\text{nm}$), is responsible for the enhanced noise. Similar results are shown for the abrasive deposition a copper-beryllium composite and gold, as well as repeated depositions of copper and stainless steel (appendix E).

The data presented so far has demonstrated that the abrasive deposition of three metallic materials, stainless steel, copper, and chromium, each result in a quenching of $T_1$-relaxation time of the NV-layer, whereas two semi-conducting materials, diamond and silicon, give no such effect. We now move to discuss the potential mechanisms by which the NV $T_1$ time could be quenched.
by abrasive depositions of metallic materials. The $T_1$-relaxation time of solid state spin qubits is sensitive to both phonon activity and magnetic noise at the qubit transition frequency. Here, we exclude the possibility of phonon-mediated quenching, given the negligible impact that the deposition has upon the diamond thermal vibrations, and discuss the magnetic contributions in terms of spin-noise and charge-noise.

Magnetic noise arising from fast-fluctuating spin-states in close proximity to the NV-layer has been previously observed to quench $T_1$ relaxation times. The data presented for stainless steel is consistent with such an explanation, where the large coverage of nano-particles, likely iron oxide, below a threshold size ($\sim 20\, \text{nm}$), exists in a superparamagnetic state, and hence quench the NV-layer $T_1$ under these regions. These findings are commensurate with previous studies of Fe$_2$O$_3$ and Fe$_3$O$_4$ at room temperature. Similar $T_1$ effects have been observed in NV sensing from modest densities of electron spins in various paramagnetic species. Therefore, a possible explanation for the $T_1$ quenching observed from the other materials studied (Cu, Cr, Au) is that they reside at the diamond surface in some paramagnetic form, which may be induced by interactions with the surface.

The metallic nature of the bulk materials whose abrasive depositions quench $T_1$-relaxation times warrants a discussion of the role played by their conductivity. Recent work in NV sensing has demonstrated enhanced $T_1$-relaxation due to charge-noise, namely Johnson-Nyquist noise arising from metallic films; an effect which scales with the conductivity of the deposited metals. These experiments, however, studied metallic films at a minimum thickness of 60 nm, due to reduced conductivity at thicknesses less than the electron mean free path. To demonstrate that quenching due to Johnson-Nyquist noise is negligible in our system for this reason, we entertain the idea that abrasive deposition results in a $\sim 1\, \text{nm}$
thin metallic film coverage, and use the model developed in Ref.\cite{14} to calculate the resulting $T_1$ quenching. Accounting for reduced conductivity in sub-mean free path thin film thicknesses, as outlined in Ref.\cite{15}, we find that the calculated noise from continuous films thicker than our depositions is insufficient to explain the observed quenching for all materials studied (appendix \text{G}). Additionally, the finite lateral extent of our particulate coverage would similarly reduce the conductivity, further discounting the possibility of $T_1$ quenching by Johnson-Nyquist noise\cite{16}.

A final possible explanation for the observed $T_1$ quenching, is by an indirect effect, where the deposited material alters the dynamics and filling of existing charge traps at the diamond surface and within the NV-layer. Reduced $T_1$ relaxation times due to thermally fluctuating low density surface states have been observed in single NV samples\cite{33}, and the strong dependence of $T_1$ times of dense near-surface NV ensembles, similar to those used in this work, on surface treatments has been noted\cite{49} (with possibly related effects seen in bulk NV samples\cite{46,50}). For these dense NV-ensembles, charge trap densities within the sensing layer can be as high as one per (nm)$^2$, corresponding to 10 charge traps created for each implanted nitrogen\cite{51}, and hence, addition of surface donors at a similar density, could substantively change the filling and dynamics of these states. The low area density of donors needed to achieve this would also explain why a perfect correlation of sample topography and $T_1$ quenching is not seen, as the density required to quench $T_1$ relaxation may be far below AFM noise floor. Imaging unpaired electron spins by double electron-electron resonance measurements is suggestive of such an indirect effect on the defects states associated with the diamond (appendix \text{C}).

In this work, we have demonstrated the application of multi-modal NV sensing to ultra-thin systems arising from the abrasive deposition of a range of materials on the diamond substrate. These systems were analysed using PL, ODMR, and $T_1$ imaging techniques, finding that the deposition of bulk metallic materials quenches the NV-layer $T_1$ relaxation, under sub-nm thick layers of material. Explanations for this effect have been discussed, including direct spin-noise and charge-noise arising from the sample, which in general cannot be separated from indirect effects that alter the population and dynamics of defects intrinsic to the diamond. This highlights an outstanding problem for NV sensing of 2D materials, namely, the need to passivate the diamond surface such that intrinsic sample properties are not conflated with induced changes to the sensing environment. Progress has been made in this area, by reducing the number of additional defects in the sensing layer\cite{11}, however, further solutions may involve targeted surface functionalisation\cite{12} or the addition of a capping layer to fix the interface chemistry close to the sensing layer. Including an electron reservoir, such that the filling of intrinsic diamond defects is robust against sample effects, is another potential solution. Success in this direction will enhance NV imaging technology for characterising the expanding library of 2D materials accessible to fabrication\cite{51,52}.

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Appendix A: Sample preparation

The NV-diamond samples used in these experiments were made from 4 mm × 4 mm × 50 μm electronic-grade ([N] < 1 ppb) single-crystal diamond plates with {110} edges and a (100) top facet, purchased from Delaware Diamond Knives and later overgrown with 2 μm of CVD diamond ([N] < 1 ppb) using 12C-enriched (99.998%) methane\cite{13}. The plates were laser cut into smaller 2 mm × 2 mm × 50 μm plates, acid cleaned (15 minutes in a boiling mixture of sulphuric acid and sodium nitrate), and implanted with $^{14}\text{N}^+$ or $^{15}\text{N}^+$ ions (InnovIon) at a fluence of $10^{13}$ ions/cm$^2$ with a tilt angle of 7$^\circ$. The implantation energy was 6 keV except for the chromium deposition in Fig. \text{4}(4 keV) and for the gold and copper depositions in Fig. \text{10}(4 keV). Such energies correspond to a mean implantation depth of about 15 nm for 6 keV and about 10 nm for 4 keV\cite{10}. Following implantation, the diamonds were annealed in a vacuum of ~10$^{-5}$ Torr to form the NV centres, using the following sequence: 6h at 400°C, 2h ramp to 800°C, 6h at 800°C, 2h ramp to 1100°C, 2h at 1200°C, 2h ramp to room temperature. To remove the graphitic layer formed during the annealing at the elevated temperatures, the samples were acid cleaned (as before).

The bulk materials that were scratched across the diamond surface were from various sources. For the stainless steel deposition, a pair of laboratory tweezers (Dumont Inox 02) was chosen and its tip scratched across the surface with moderate pressure. The resulting depositions were similar in appearance to features observed on other samples, likely arising from an accidental contamination during routine sample preparation. Similarly, the tip of a diamond scribe was scratched across the sample surface to form the cavitations shown in Fig. \text{4}. A sharp piece of silicon, cleaved from a larger wafer was used for the silicon deposition. Of the metallic sample, the gold
and chromium were taken from pellets used in e-beam evaporation, with a purity $> 99.95\%$. The copper used was an off-cut from a larger copper sheet, whose purity is unknown. All bulk materials were cleaned using acetone and isopropyl alcohol prior to making contact with the diamond surface.

### Appendix B: Background characterisation and optical imaging

Prior to the abrasive deposition of the materials studied in this work, a thorough background characterisation was undertaken for each targeted area. All ensemble NV diamonds used in this work were cleaned by a Bristol boil technique (boiling mixture of sulfuric acid and sodium nitrate), prior to background characterisation and abrasive deposition. The areas characterised were chosen due to their close proximity to pyramid structures in the diamond surface, arising from the growth procedure, which served as markers by which the regions of interest could be located [Fig. 5a]. The background PL, $T_1$, and static field images for the region later scratched with stainless steel, are shown in Figs. 5b-d. Each of the background images are free of the features highlighted in post-scratch figures in the main text, indicating that the identified features can be attributed to the abrasive deposition. A slight modulation of the background $T_1$ that is correlated with the laser illumination is observed, which we attribute to an imperfect NV spin initialisation, and highlights potential issues in interpreting $T_1$ features strongly correlated with PL. Similar background characterisations were undertaken for the regions deposited with the other materials exhibited in the paper.

In addition the NV based imaging presented in the main text, standard bright-field optical microscopy of the regions of interest was performed, by illuminating the sample with a simple lamp. Figure 6a and b shows optical micrographs of the stainless steel region of interest before and after the abrasive deposition. The images are practically identical with the exception of a collection of dark shadows cast in regions located within areas of greater PL quenching, which were associated with particulate inclusions approaching micron scales. The lack of optical contrast from the deposited layer was the first suggestion that the deposited layer is indeed thin, as was later confirmed by AFM imaging.

### Appendix C: Static magnetic field mapping by ODMR

The ODMR spectrum integrated across the entire stainless steel region of interest is shown in Fig. 7 showing the eight clearly resolved transitions from the four NV families. Using the splitting of the ODMR resonance frequencies for the different NV families, the Cartesian components of the vector magnetic field can be deduced as explained in Refs. 21, 22. In the analysis, we neglected the possible presence of strain and electric field, which is expected to have a negligible impact on the reconstructed magnetic field. The magnetic field map, reconstructed from pixel-by-pixel fitting of the transition frequencies, in the x- and z-directions, are shown in Figs. 7b and c. The static field in the x-direction, $B_x$, closely resembles that in the y-direction, $B_y$, shown in the main text. The field in the z-direction, however, is reduced significantly in magnitude as compared to the in-plane counterparts. This effect, analysed in detail in Ref. 21, arises from the close proximity of the sensing layer to the ferromagnetic nanoparticles, where the strong fields seen by the closest NV centres result in them being neglected by the measurements and fitting routines, and hence, the signal is dominated by those seeing lesser field strengths within the same optically resolvable sensing volume.

![FIG. 5. a PL image of the extended area surrounding the region in which stainless steel was deposited (white box). The bright diamond pyramids were used to reliably align the image, and compare data before and after deposition. b Background PL characterisation of the target region for stainless steel deposition. c Background static field map, $B_z$, of same region. d Background $T_1$-relaxation map showing a slight modulation, correlated with the laser illumination, of the otherwise clean region.](image)

![FIG. 6. Optical micrographs of the stainless steel region before, a, and after, b, the abrasive deposition. Some dark shadows are seen in regions associated with regions seen to exhibit great PL quenching.](image)
FIG. 7. a ODMR spectrum integrated across the entire stainless steel region of interest. b and c show the reconstructed static magnetic field maps in the y-direction, $B_y$, and z-direction, $B_z$, respectively. d Linewidth map of the lowest frequency NV spin-transition. This was the same transition for which the optical contrast was mapped in Fig. 2d.

In the main text, the ODMR contrast map was used to infer a more complex interaction between the NV-layer and deposited material. The reduced contrast seen under the deposited area could result from a broadening of the peaks due to the deposited material, through a static spread in magnetic field, or magnetic fluctuations. However, mapping the width of a single peak, again the lower frequency transition, we see that the width is only significantly increased due to the fields arising from the ferromagnetic nanoparticles, an expected result. This implies that the reduced ODMR contrast in the abraded regions is not directly caused by the deposited material, and must instead explained by a more subtle effect whereby the photo-dynamics of the NV is affected in a way that results, for instance, in a reduced spin initialisation.

Appendix D: EDXS of stainless steel deposition

One of the outstanding challenges in working with atomically thin samples on a rough diamond surface, is characterising the deposited materials independently to the NV measurements. Raman spectroscopy was attempted on similar samples to those presented in the main text, however, their small contribution to the total sensing volume and the background fluorescence of the NV layer make this a particularly difficult measurement. Energy-dispersive X-ray spectroscopy (EDXS) is a useful technique for characterising such samples, as it combines high-resolution SEM imaging, which typically shows contrast between bare substrates and monolayer coverage, with spectroscopy that can identify the atomic composition of larger particles (> 100 nm). Here we present results for an stainless steel deposited sampled, similarly prepared to that presented in the main text.

Figure 8a shows an SEM image of the deposited region, showing features similar to those seen in the SEM imaging of the sample presented in the main text. A banded streak, approximately 5 µm wide, is seen with larger particles embedded in it. The EDXS spectra of these particles show the presence of Fe and O in abundances commensurate with Fe$_2$O$_3$ and Fe$_3$O$_4$ (labels on Fig. 8a give the atomic abundances excluding the dominant C peak from the substrate). A representative spectrum of these particles is shown in Fig. 8b, where the high energy peak at low energy is characteristic of carbon. It is important to note that spectrum 7 in Fig. 8a, acquired from a region of the streak free of large particles, shows only the presence of oxygen, likely due to the surface termination of the diamond, again suggesting a sparse coverage of material from the abrasive deposition.
Appendix E: Comparison of abrasively deposited materials

In the main text, PL, $T_1$ and AFM data was presented for a range of materials, to compare the consequences of their deposition on diamond. The NV imaging data presented was restricted to regions for which spatially correlated AFM imaging was achieved, however, all imaging was acquired over an approximately 100 µm field of view. Here we present the full field of view data for the PL and $T_1$ imaging for completeness.

Figure 9 shows the full field of view PL and $T_1$ images of the sample regions scratched with a diamond scribe, silicon wafer, copper, and chromium. The scribe region shows a large cavitation pattern in PL [Fig. 9b], due to the removal of NV centres and the consequent destabilisation of the NV charge as discussed, however, the $T_1$ is largely unchanged [Fig. 9f]. Similarly, the silicon wafer region shows a clear band of quenched PL [Fig. 9g], a small region of which was presented in the main text, with bright centres arising from larger Si particles (> 1 µm), but again, no significant change in $T_1$. Background characterisation of the copper region, which was centered around a growth pyramid [Fig. 9d], revealed a pre-existing $T_1$ boundary, where the left hand side of the imaged region has a slightly shorter relaxation time than the right. This feature remained after the copper deposition, which did not directly affect PL [Fig. 9c], but quenched the $T_1$ [Fig. 9f]. The region for which correlated AFM was achieved lay to the left hand side of the pyramid. The large feature seen to the right hand side of the pyramid is a large chunk of metallic copper, which shows bright in PL, and strongly quenches $T_1$. No discernible step height was measured across the steak of quenched $T_1$ running across the centre of the image. Finally, the chromium deposited region shows only a slight PL quenching parallel to the scratch direction as discussed in the main text [Fig. 9f], whereas the $T_1$ quenching is significant [Fig. 9f].

In addition to the materials discussed above for which spatially correlated AFM data was collected, additional scratches were made with a range of secondary materials, for which only NV data was collected. The PL and $T_1$ images of regions scratched with a copper-beryllium composite, gold, copper, and stainless steel are shown in Figs. 10a - d and Figs. 10e - h respectively. None of the materials show particularly strong PL quenching, with the exception of stainless steel which shows a stronger quenching than shown in the main text (the bright regions seen for the copper-beryllium scratches as due to large chunks of the composite sitting on the surface, and the dark lines running horizontally across the field of view were pre-existing scratches in the sample [Fig. 10a]) but all result in clear quenching of the NV-layer $T_1$ relaxation time. Here the total added noise for each deposition is 0.6 kHz, 0.7 kHz, 2.0 kHz, and 5.0 kHz for the copper-beryllium, gold, copper, and stainless steel respectively. The added noise was calculated by comparing the $T_1$ times under and beside the abraded regions for the copper-beryllium, copper, and stainless steel, where the gold compared to a background measurement, as the $T_1$ decreased across the entire field of view after the scratch due to the blunt nature of the macroscopic block used. The result for gold is particularly interesting given it lacks a candidate form for the spin-noise origin, suggesting the effect is likely an indirect effect one on the diamond itself. We note that the gold abrasion was performed on a polished diamond surface, which is responsible for the grating (polishing marks) visible in Fig. 10.

Appendix F: Johnson-Nyquist noise from metallic thin films

Ref.43 derive a model for the relaxation rate induce by Johnson-Nyquist noise arising from a metallic film as

$$\Gamma_{metal} = \gamma \frac{\mu_0^2 k_B T \sigma}{8 \pi} \left( \frac{1}{d} - \frac{1}{d + t_{film}} \right) \quad (F1)$$

where $\gamma$ is the electron gyromagnetic ratio, $\mu_0$ is the vacuum permeability, $T$ is temperature, $\sigma$ is the metal conductivity, $d$ is the separation between the sensing layer and the metallic film, which has thickness $t_{film}$. Calculating the expected noise for a film thickness of 1 nm with the conductivity of bulk copper, $\sigma = 6.0 \times 10^7 \, \Omega^{-1} \, m^{-1}$, gives a noise $\Gamma_{metal} = 2.0 \, kHz$. However, once the reduced conductivity at film thicknesses less than the mean free path are taken into account, which, conservatively, reduces conductivity by an order of magnitude at a 5 nm film thickness, the calculated noise is well below that observed for even the lower conductivity metals that were abrasively deposited. Additionally, this model does not account for the lateral confinement of our particular deposition, which will only further reduce the conductivity.

Appendix G: Double electron-electron resonance imaging

Double electron-electron resonance (DEER) is a standard technique in NV sensing used to detect electron spin species. Target species within some frequency range are driven synchronously with a spin-echo sequence driven on one family of the NV layer, resulting in a detectable phase accumulation. Figure 11b shows the DEER spectrum integrated across the entire stainless steel deposited region (identical to the region shown in Figs. 1 and 2), taken at 437 G. Here we fit the frequency of the free-electron peak (centre), with a fixed relative shift of the substitutional nitrogen (P1) peak, given by the transverse hyperfine coupling parameters with the 14N nucleus, and produce maps of the contrast [Figs. 11b and c] and width [Figs. 11d and e] of each peak.
The optical contrast of both the free-electron peak and the central P1 peak [Figs. 11b and c] closely resembles the optical contrast map of the NV ODMR measurement, which again suggests that the charge stability of the NV centre are affected during the dark time of the measurement. Comparing the widths of the two peaks across the field of view, both are broadened at the sites of ferromagnetism, as for the NV ODMR, but the free-electron peak is narrowed under the abraded region, possibly due to an increase in spin dephasing time of the free electrons. If this change in spin dynamics was purely due to added magnetic noise coming from the sample, it would also be present on the P1 peak. We therefore conclude that the effect is related to a change in population (charge) dynamics which can affect the two species differently (due to different energy levels), which in turn affect the spin dynamics differently. This suggests that the deposited material has an effect on the charge dynamics inside the diamond (e.g. at vacancy defects), which is a candidate to explain the change in NV $T_1$.

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FIG. 11. a DEER spectrum centred around the free-electron peak at 437 G. The large central peak is associated with free-electron spins. The shoulder and five outer peaks are associated the electron spin of substitutional nitrogen (P1) centres intrinsic to the diamond. b and c DEER spectrum peak contrast for the central free-electron, and P1 shoulder peaks respectively. d and e Width maps of the free-electron and central P1 peaks respectively.


